

SOLUTIONS:

Problem 1:

Using <https://www.pvlighthouse.com.au/resistivity> to obtain $\rho = 2.346 \, \Omega \cdot \text{cm}$

$$R = \rho * \frac{L}{w * t} = 2.346 * \frac{30}{2 * 0.5} * 10^2 = 7.038 \, k\Omega$$

Problem 2:

$$I_d = J_s A \left(e^{\frac{V_D}{V_T}} - 1 \right) = \left(100 \, \mu\text{m}^2 * \frac{10^{-15} \text{A}}{\mu\text{m}^2} \right) * \left(e^{\frac{0.5\text{V}}{26\text{mV}}} - 1 \right) = 22.5 \, \mu\text{A}$$

$$I_d = J_s A \left(e^{\frac{V_D}{V_T}} - 1 \right) = \left(100 \, \mu\text{m}^2 * \frac{10^{-15} \text{A}}{\mu\text{m}^2} \right) * \left(e^{\frac{0.6\text{V}}{26\text{mV}}} - 1 \right) = 1.05 \, \text{mA}$$

Problem 3:

$$I_d = \left(\frac{10^{-15} \text{A}}{\mu\text{m}^2} * 100 \, \mu\text{m}^2 \right) \left(e^{\frac{V_D}{26\text{mV}}} - 1 \right)$$

$$5\text{V} = 2\text{k}\Omega * I_d + V_D$$

Solve system of equations, $I_d = 2.19 \, \text{mA}$

Problem 4:

$$I_d = \left(\frac{10^{-15} \text{A}}{\mu\text{m}^2} * 100 \, \mu\text{m}^2 \right) \left(e^{\frac{V_D}{26\text{mV}}} - 1 \right)$$

$$520\text{mV} = 2\text{k}\Omega * I_d + V_D$$

Solve system of equations, $I_d = 16.2 \, \mu\text{A}$

Problem 5:

In TSMC 0.18μ CMOS process,

$$V_{GS} = 1.8V, V_{th} = 0.50V, \frac{\mu_{COX}}{2} = \frac{171.8\mu s}{v^2}$$

$$R_{FET} = \frac{V_{ds}}{I_D} = \left[\mu_n * C_{OX} * \frac{W}{L} * (V_{GS} - V_T) \right]^{-1} = 4000$$

$$\frac{W}{L} = \frac{1}{4000 * (2 * 171.8 * 10^{-6}) * (1.8 - 0.50)} = 0.5597$$

In the AMIS 0.5 μ CMOS Process,

$$V_{GS} = 3.5V, V_{th} = 0.79V, \frac{\mu_{COX}}{2} = \frac{57.8\mu s}{v^2}$$

$$R_{FET} = \frac{V_{ds}}{I_D} = \left[\mu_n * C_{OX} * \frac{W}{L} * (V_{GS} - V_T) \right]^{-1} = 4000$$

$$\frac{W}{L} = \frac{1}{4000 * (2 * 57.8 * 10^{-6}) * (3.5 - 0.79)} = 0.7980$$

In the IBM 0.13 μ CMOS Process,

$$V_{GS} = 1.5V, V_{th} = 0.41V, \frac{\mu_{COX}}{2} = \frac{308.0\mu s}{v^2}$$

$$R_{FET} = \frac{V_{ds}}{I_D} = \left[\mu_n * C_{OX} * \frac{W}{L} * (V_{GS} - V_T) \right]^{-1} = 4000$$

$$\frac{W}{L} = \frac{1}{4000 * (2 * 308.0 * 10^{-6}) * (1.5 - 0.41)} = 0.3723$$

Problem 6:

For a minimum sized transistor in IBM 0.13μ CMOS process, with $V_{GS} = 1.5V$ and $W/L = 0.16\mu/0.12\mu$, POLY-N+active capacitance = $11176 \text{ aF}/\mu\text{m}^2$, POLY-P+active capacitance = $10496 \text{ aF}/\mu\text{m}^2$

$$C_{GSN} = (0.16)(0.12)(11176 * 10^{-18}) = 214.579 \text{ aF}$$

$$C_{GSP} = (0.16)(0.12)(10496 * 10^{-18}) = 201.523 \text{ aF}$$

$$C_L = C_{ASP} + C_{GSN} = 416.102 \text{ aF} = 0.416 \text{ fF}$$

For a minimum sized transistor in TSMC 0.18μ CMOS process. With $V_{GS} = 1.5V$, $V_{TH} = 0.5V$ and

$$W/L = 0.27\mu/0.18\mu, \frac{\mu_{COXn}}{2} = \frac{171.8\mu s}{v^2}, \frac{\mu_{COXP}}{2} = \frac{-36.3\mu s}{v^2}$$

$$R_{SWN} = \left(\frac{2 * 171.8 * 10^{-6} * 0.27}{0.18} * (1.5 - 0.5) \right)^{-1} = 1.940 \text{ k}\Omega$$

$$R_{SWP} = \left(\frac{2 * -36.3 * 10^{-6} * 0.27}{0.18} * (-1.5 - 0.5) \right)^{-1} = 9.183 \text{ k}\Omega$$

$$T_{HL} = 1.940k * 416.102a = 0.807pS$$

$$T_{LH} = 9.183k * 416.102a = 3.821pS$$

Problem 7:

$$I_{D1} = \left(\frac{5 * 10^{-15} A}{\mu m^2} * 200 \mu m^2 \right) \left(e^{\frac{V_D}{258mV}} - 1 \right)$$

$$I_{D2} = \left(\frac{5 * 10^{-15} A}{\mu m^2} * 800 \mu m^2 \right) \left(e^{\frac{V_D}{258mV}} - 1 \right)$$

$$I_{D2} = 4 * I_{D1}$$

$$\left(\frac{1.5 - V_D}{1000} \right) = I_{D1} + I_{D2} = 5I_{D1} = (5 * 10^{-12}) (e^{\frac{V_D}{258mV}} - 1)$$

Solve for $V_D \approx 0.493 V$

$$I_{D1} \approx 0.198 mA$$

Problem 8:

a) Assume saturation:

$$I_{D1} = \left(300 * 10^{-6} * \frac{6}{2 * 2} (1 - 0.5)^2 \right) = 0.1125mA \rightarrow V_{out} = 1.8 - 4 * 0.1125 = 1.35V$$

b) Assume triode:

$$\frac{(1.8 - V_{DS})}{25k} = 300 * 10^{-6} * \frac{12}{1.5} * \left(1.2 - 0.5 - \frac{V_{DS}}{2} \right) V_{DS}$$

Solve for $V_{DS} = V_{out} = 0.043V$

c) Assume saturation:

$$I_{D3} = \frac{300}{4} * 10^{-6} * \frac{6}{4} * (0.8 - 0.5)^2 = 10.125 \mu A \rightarrow V_{out} = 25k * 10.125\mu = 0.253 V$$

Problem 9:

a) Assuming saturation for both transistors, $V_{out} = x$

$$I_{ds1} = \left(\frac{300\mu}{2}\right)\left(\frac{6}{2}\right)(x - 0.5)^2 \quad \& \quad I_{ds2} = \left(\frac{300\mu}{8}\right)\left(\frac{2}{6}\right)(1.8 - x - 0.5)^2$$

$$I_{ds1} = I_{ds2}, \text{ solve for } x = V_{out} = 0.6143 \text{ V}$$

b) Assuming saturation for both transistors

$$150 \mu A = \left(\frac{300\mu}{8}\right)\left(\frac{8}{2}\right)(V_G - 1.8 + 0.5)^2 \rightarrow V_G = 0.3 \text{ V}$$

$$I_{ds2} = \left(\frac{300\mu}{8}\right)\left(\frac{12}{4}\right)(0.3 - 1.8 + 0.5)^2 = 112.5 \mu A$$

$$V_{out} = 1.8 - 112.5\mu * 8k = 0.9 \text{ V}$$

Problem 10:

Code:

```
1 module decoder(A,B,C,Y);
2   input A,B,C;
3   output reg[7:0] Y;
4   always @ *
5     case ({A,B,C})
6       3'b000: Y = 8'b00000001;
7       3'b001: Y = 8'b00000010;
8       3'b010: Y = 8'b00000100;
9       3'b011: Y = 8'b00001000;
10      3'b100: Y = 8'b00010000;
11      3'b101: Y = 8'b00100000;
12      3'b110: Y = 8'b01000000;
13      3'b111: Y = 8'b10000000;
14    endcase
15  endmodule
```

Test Bench:

```
1 module decoder_tb();
2   reg A,B,C;
3   wire[7:0] Y;
4   decoder D(A,B,C,Y);
5
6   initial
7   begin
8     A = 0;
9     B = 0;
10    C = 0;
11  end
12
13  always
14  #10 C = ~C;
15  always
16  #20 B = ~B;
17  always
18  #40 A = ~A;
19
20 endmodule
```

Waveform:

